Application No. 10/008,838

-5-

BEST AVAILABLE COPY

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims: 1-13. (CANCELLED)

3

4

5

6

7

8

9

11 12

13

14

15

16

1 14. (currently amended) A method of fabricating an acoustic resonator comprising the steps of:

providing a substrate; and

forming a membrane on said substrate such that at least a portion of said membrane is suspended from contact with a substrate, including:

forming an electrode-piezoelectric stack on said substrate
such that a portion of said electrode-piezoelectric stack is suspended from
contact with said substrate by a cavity having a boundary defined by said
electrode-piezoelectric stack, said electrode-piezoelectric stack having a
negative temperature coefficient of frequency, and

(a) forming an electrode-plezoelectric stack having a negative temperature coefficient of frequency, and

(a) forming (b) forming a compensator layer, comprised of a ferromagnetic material, in direct contact with adjacent to said electrode-piezoelectric stack, including selecting a material for said compensator layer

- 17 having a positive temperature coefficient of frequency.
- 1 15. (currently amended) The method of claim 14 wherein said step (a)
- 2 stop (b) that includes selecting said material includes selecting a nickel-iron
- 3 alloy.
- 1 16. (currently amended) The method of claim 14 wherein said step (a)
- 2 step (b) Includes depositing said material as approximately 35 percent nickel
- 3 and approximately 65 percent iron.

-6-

- 1 17. (currently amended) The method of claim 14 wherein said step (a)
- 2 step (b) includes selecting a layer thickness to substantially match a
- 3 magnitude of temperature-induced effects on resonance by operation of said
- 4 electrode-piezoelectric stack with a magnitude of temperature-induced effects
- 5 on said resonance as a consequence of said compensator layer.
- 1 18. (currently amended) The method of claim 14 wherein said step of
- 2 forming said compensator layer membrane further includes (b) forming
- 3 (c) forming a metallic flashing layer on a side of said compensator layer
- 4 opposite to said electrode-piezoelectric stack.
- 1 19. (currently amended) The method of claim 18 further comprising using
- 2 fabrication alignment techniques in said steps (a) and (b) steps (b) and (c) to
- 3 prevent spurious mode generation resulting from partial coverage of said
- 4 suspended membrane electrode-piezoelectric stack by said compensator
- 5 layer er-said flashing layer.

This Page is Inserted by IFW Indexing and Scanning Operations and is not part of the Official Record

BEST AVAILABLE IMAGES

Defective images within this document are accurate representations of the original documents submitted by the applicant.

Defects in the images include but are not limited to the items checked:

BLACK BORDERS

IMAGE CUT OFF AT TOP, BOTTOM OR SIDES

FADED TEXT OR DRAWING

BLURRED OR ILLEGIBLE TEXT OR DRAWING

SKEWED/SLANTED IMAGES

COLOR OR BLACK AND WHITE PHOTOGRAPHS

GRAY SCALE DOCUMENTS

LINES OR MARKS ON ORIGINAL DOCUMENT

REFERENCE(S) OR EXHIBIT(S) SUBMITTED ARE POOR QUALITY

IMAGES ARE BEST AVAILABLE COPY.

OTHER:

As rescanning these documents will not correct the image problems checked, please do not report these problems to the IFW Image Problem Mailbox.